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Abstract of the Disclosure



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A radiation sensitive composition comprising (A) a colorant containing a pigment, (B) an alkali-soluble resin, (C) a polyfunctional monomer and (D) a photopolymerization initiator, having an erosion rate of a 20 μ m dot pattern formed therefrom of 30 % or less, and used to form a spacer and/or a black matrix on a drive substrate for a thin film transistor (TFT) color liquid crystal display device.

This composition has a low erosion rate of a pattern formed therefrom, thereby making it difficult for the formed pattern to be tapered reversely at the time of development, can prevent effectively rubbing cloth from being caught by a pattern portion and the separation of the pattern, is free from a display failure such as image sticking and is used to form a spacer and/or a black matrix on a drive substrate for a thin film transistor (TFT) color liquid crystal display device.